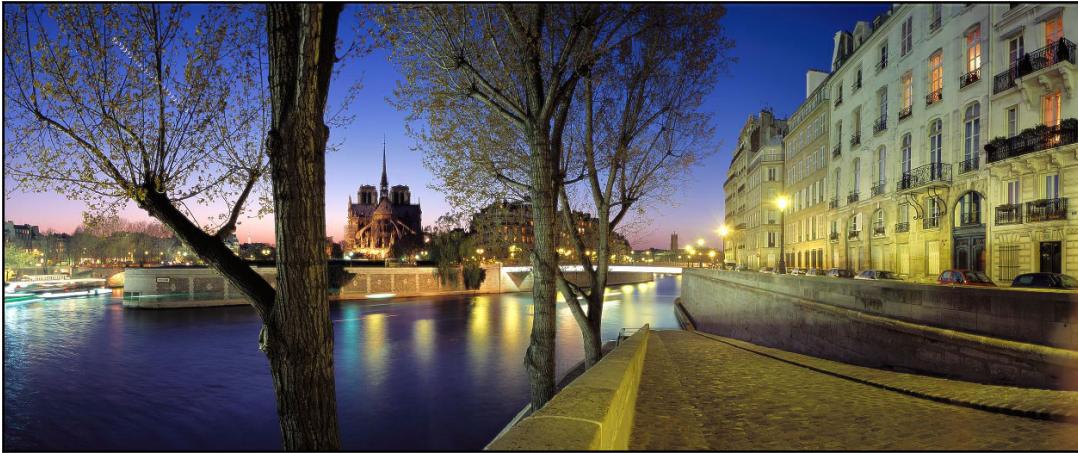


On behalf of the European Network of Excellence NANOFUN-POLY
We are pleased to announce the organization of the



5th International ECNP Conference on
NANOSTRUCTURED POLYMERS AND NANOCOMPOSITES

which will take place in Paris, France
from April 15th to 17th, 2009
at Arts & Métiers ParisTech
Bld. de l'Hospital, Paris (Metro Place d'Italie)

This symposium is organized by IMP UMR#5223 Lyon - ECNP
in collaboration with Arts et Métiers ParisTech

Scientific topics:

Chemistry of nanostructured polymers and copolymers
Physics of soft matter in nanostructured polymers: relaxation phenomena,
optoelectronic and magnetic properties
Nanostructured blends and copolymers
Nanofillers: carbon nanotubes and nanofibers, hybrids, POSS, nanocellulose
Nanostructured coatings and adhesives
Processing of nanostructured polymers and nanocomposites
Advanced characterization techniques
Mathematical modelling
Life Cycle Analysis

Organizing Committee (ECNP/NANOFUN-POLY)
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www.nanofun-poly.org, www.ecnp.eu.org
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CONFERENCE VENUE

The conference will be held at the amphitheatre of Arts et Métiers ParisTech located in Bld. de l'Hôpital, Paris (Metro Station: Place d'Italie).

DEADLINES

A 1-page abstract, inclusive of graphs and references with author name, address, e-mail, phone and fax number should be sent by January 31, 2009, to sylvain.baudu@insa-lyon.fr

January 31, 2008 Submission of Abstracts

February 15, 2008 Acceptance of Abstracts

All papers will be considered for eventual publication in the international scientific journal launched by NANOFUN-POLY: *Journal of Nanostructured Polymers & Nanocomposites*.

CONFERENCE REGISTRATION FEES

The conference registration fees cover:

- Admission to three days conference sessions
- Welcome reception, coffee breaks and Conference Banquet
- Book of abstracts and pen drive

Registration and Payment until March 1, 2009:

Participants: Euro 400, Students: Euro 200 (letter from advisor requested)

Registration and Payment after March 1, 2009:

Participants: Euro 450, Students: Euro 250

Contact address for registration

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ACCOMODATION

Accommodation will be not provided by the Conference organization, since Paris is well served with a wide selection of hotels. The conference site is in down town Paris, a few steps from Place d'Italie.

www.nanofun-poly.org, www.ecnp.eu.org

